PCT

WORLD INTELLECTUAL PROPERTY ORGANIZATION International Bureau

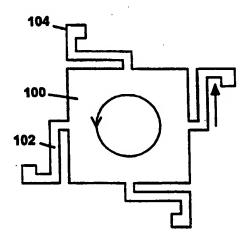


INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification ⁶ :		(11) International Publication Number: WO 99/52006
G02B 26/02	A3	(43) International Publication Date: 14 October 1999 (14.10.99)
(21) International Application Number: PCT/US	99/072	71 (81) Designated States: KR, US.
(22) International Filing Date: 1 April 1999 (01.04.9	9) Published
(30) Priority Data: 09/056,975 8 April 1998 (08.04.98)	τ	With international search report. Before the expiration of the time limit for amending the claims and to be republished in the event of the receipt of amendments.
(63) Related by Continuation (CON) or Continuation-in (CIP) to Earlier Application US 09/056,97 Filed on 8 April 1998 (75 (CO	
 (71) Applicant (for all designated States except US): INC. [US/US]; Suite 501, 354 Congress Street, Bo 02110-1237 (US). (72) Inventor; and (75) Inventor/Applicant (for US only): MILES, Mark, W. 	ETALO oston, M	N, IA
Suite 501, 354 Congress Street, Boston, MA 02 (US).	110–12	37
(74) Agent: FEIGENBAUM, David, L.; Fish & Richard 225 Franklin Street, Boston, MA 02110-2804 (US)		C.,
(54) Title: INTERFEROMETRIC MODULATION OF R	RADIA	TION

(57) Abstract

The invention features an interferometric modulator comprising a cavity defined by two walls. At least two arms connect the two walls to permit motion of the walls relative to each other. The two arms are configured and attached to a first one of the walls in a manner that enables mechanical stress in the first wall to be relieved by motion of the first wall essentially within the plane of the first wall.



FOR THE PURPOSES OF INFORMATION ONLY

Codes used to identify States party to the PCT on the front pages of pamphlets publishing international applications under the PCT.

AL	Albania	ES	Spain	LS	Lesotho	SI	Slovenia
AM	Armenia	FI	Finland	LT	Lithuania	SK	Slovakia
AT	Austria	FR	France	LU	Luxembourg	SN	Senegal
AU	Australia	GA	Gabon	LV	Latvia	SZ	Swaziland
AZ	Azerbaijan	GB	United Kingdom	MC	Monaco	TD	Chad
BA	Bosnia and Herzegovina	GE	Georgia	MD	Republic of Moldova	TG	Togo
BB	Barbados	GH	Ghana	MG	Madagascar	TJ	Tajikistan
BE	Belgium	GN	Guinea	MK	The former Yugoslav	TM	Turkmenistan
BF	Burkina Faso	GR	Greece		Republic of Macedonia	TR	Turkey
BG	Bulgaria	HU	Hungary	ML	Mali	TT	Trinidad and Tobago
BJ	Benin	IE	Ireland	MN	Mongolia	UA	Ukraine
BR	Brazil	IL	Israel	MR	Mauritania	UG	Uganda
BY	Belarus	IS	Iceland	MW	Malawi	US	United States of America
CA	Canada	IT	Italy	MX	Mexico	UZ	Uzbekistan
CF	Central African Republic	JP	Japan	NE	Niger	VN	Viet Nam
CG	Congo	KE	Kenya	NL	Netherlands	YU	Yugoslavia
CH	Switzerland	KG	Kyrgyzstan	NO	Norway	zw	Zimbabwe
CI	Côte d'Ivoire	KP	Democratic People's	NZ	New Zealand		
CM	Cameroon		Republic of Korea	PL	Poland		
CN	China	KR	Republic of Korea	PT	Portugal		
CU	Cuba	KZ	Kazakstan	RO	Romania		
CZ	Czech Republic	LC	Saint Lucia	RU	Russian Federation		
DE	Germany	LI	Liechtenstein	SD	Sudan		
DK	Denmark	LK	Sri Lanka	SE	Sweden		
EE	Estonia	LR	Liberia	SG	Singapore		
ĺ							

Internatic Application No PCT/US 99/07271

A. CLASSIF IPC 6	GO2B26/02		
According to	International Patent Classification (IPC) or to both national classific	ation and IPC	
B. FIELDS	SEARCHED		
Minimum do IPC 6	cumentation searched (classification system followed by classificat G02B B81C G09F	ion symbols)	
	ion searched other than minimum documentation to the extent that		rohed
Electronic d	ata base consulted during the international search (name of data bu	sse and, where practical, search terms used)	
C. DOCUMI	ENTS CONSIDERED TO BE RELEVANT		
Category *	Citation of document, with indication, where appropriate, of the re	elevant passages	Relevant to claim No.
Х	WO 95 30924 A (ETALON INC ;MILE: (US)) 16 November 1995 (1995-11	-16)	1-8,10, 11,15, 23,24
A	page 33, line 20 -page 34, line 28	15; figure	14
		-/	
į			
			•
X Fur	ther documents are listed in the continuation of box C.	X Patent family members are listed	n annex.
* Special c	ategories of cited documents :	"T" later document published after the lints	mational filing date
A. docum	nent defining the general state of the art which is not	or priority date and not in conflict with cited to understand the principle or the	ory underlying the
"E" earlier	idered to be of particular relevance document but published on or after the international	invention "X" document of particular relevance; the o	laimed Invention
filing	ent which may throw doubts on priority claim(s) or	cannot be considered novel or cannot involve an inventive step when the do	oument is taken alone
citati	n is cited to establish the publication date of another on or other special reason (as specified)	"Y" document of particular relevance; the cannot be considered to involve an independent in combined with one or more	ventive step when the
other	nent referring to an oral disclosure, use, exhibition or reans	document is combined with one or no ments, such combination being obvio in the art.	us to a person skilled
P docum	nent published prior to the international filing date but than the priority date claimed	"&" document member of the same patent	family
Date of the	actual completion of the international search	Date of mailing of the international sec	roh report
	12 August 1999	10. 11. 1	999
Name and	mailing address of the ISA	Authorized officer	
	European Patent Office, P.B. 5818 Patentiaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo ni, Fax: (+31-70) 340-3018	SCHEU, M	

1

Internat Application No PCT/US 99/07271

ation) DOCUMENTS CONSIDERED TO BE RELEVANT	10.
Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
ARATANI K ET AL: "PROCESS AND DESIGN CONSIDERATIONS FOR SURFACE MICROMACHINED BEAMS FOR A TUNEABLE INTERFEROMETER ARRAY IN SILICON" PROCEEDINGS OF THE WORKSHOP ON MICRO ELECTRO MECHANICAL SYSTEMS (ME, FORT LAUDERDALE, FEB. 7 - 10, 1993, no. WORKSHOP 6, 7 February 1993 (1993-02-07), pages 230-235, XP000366885 INSTITUTE OF ELECTRICAL AND ELECTRONICS ENGINEERS ISBN: 0-7803-0957-X page 232	1-8,10, 11,15
GOOSSEN K W ET AL: "SILICON MODULATOR BASED ON MECHANICALLY-ACTIVE ANTI-REFLECTION LAYER WITH 1 MBIT/SEC CAPABILITY FOR FIBER-IN-THE-LOOP APPLICATIONS" IEEE PHOTONICS TECHNOLOGY LETTERS, vol. 6, no. 9, 1 September 1994 (1994-09-01), pages 1119-1121, XP000468079 ISSN: 1041-1135 the whole document	1-7, 9-11,15
EP 0 667 548 A (AT & T CORP) 16 August 1995 (1995-08-16) column 3, line 12 - line 35 column 4, line 54 -column 6, line 30; figure 2	1-7, 9-11,15
	ARATANI K ET AL: "PROCESS AND DESIGN CONSIDERATIONS FOR SURFACE MICROMACHINED BEAMS FOR A TUNEABLE INTERFEROMETER ARRAY IN SILICON" PROCEEDINGS OF THE WORKSHOP ON MICRO ELECTRO MECHANICAL SYSTEMS (ME, FORT LAUDERDALE, FEB. 7 - 10, 1993, no. WORKSHOP 6, 7 February 1993 (1993-02-07), pages 230-235, XP000366885 INSTITUTE OF ELECTRICAL AND ELECTRONICS ENGINEERS ISBN: 0-7803-0957-X page 232 GOOSSEN K W ET AL: "SILICON MODULATOR BASED ON MECHANICALLY-ACTIVE ANTI-REFLECTION LAYER WITH 1 MBIT/SEC CAPABILITY FOR FIBER-IN-THE-LOOP APPLICATIONS" IEEE PHOTONICS TECHNOLOGY LETTERS, vol. 6, no. 9, 1 September 1994 (1994-09-01), pages 1119-1121, XP000468079 ISSN: 1041-1135 the whole document EP 0 667 548 A (AT & T CORP) 16 August 1995 (1995-08-16) column 3, line 12 - line 35 column 4, line 54 -column 6, line 30;

1

 $\mathbf{r} = (\mathbf{r}_{\mathbf{r}}, \mathbf{r}_{\mathbf{r}}, \mathbf{r}_{\mathbf{r}}, \mathbf{r}_{\mathbf{r}})$

International application No. PCT/US 99/07271

Box I Observations where certain claims were found unsearchable (Continuation of Item 1 of first sheet)
This International Search Report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:
Claims Nos.: because they relate to subject matter not required to be searched by this Authority, namely:
2. Claims Nos.: because they relate to parts of the International Application that do not comply with the prescribed requirements to such an extent that no meaningful International Search can be carried out, specifically:
3. Claims Nos.: because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).
Box II Observations where unity of invention is lacking (Continuation of item 2 of first sheet)
This International Searching Authority found multiple inventions in this international application, as follows:
As all required additional search fees were timely paid by the applicant, this International Search Report covers all searchable claims.
As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.
3. As only some of the required additional search fees were timely paid by the applicant, this International Search Report covers only those claims for which fees were paid, specifically claims Nos.:
4. No required additional search fees were timely paid by the applicant. Consequently, this International Search Report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.: 1-15,23,24
Remark on Protest The additional search fees were accompanied by the applicant's protest. No protest accompanied the payment of additional search fees.

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210

1. Claims: 1-15,23,24

An interferometric modulator comprising a cavity defined by two walls wherein the first wall is movable relative to the second wall and within the plane of the first wall

2. Claims: 16-18

Interferometric modulator comprising three walls and control circuitry for driving at least one of three walls

3. Claims: 19-20

an interference modulator comprising spacers mounted to form part of one of the walls

4. Claims: 21,22,25

Interference modulator comprising means to control the response time of the modulator

5. Claim: 26

6. Claims: 27-32

An interferometric modulator, comprising walls and a support and at least one of the walls or the support comprising at least two materials

7. Claims: 33-38,44-48

A method of etching and patterning a microelectromechanical structure

8. Claims: 39-43

a method of making arrays of microelectromechanical structure on a production line

18.50

intermation on patent family members

Interna' 1 Application No
PCT/US 99/07271

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
WO 9530924 A	16-11-1995	US 5835255 A EP 0801766 A JP 10500224 T	10-11-1998 22-10-1997 06-01-1998
EP 0667548 A	16-08-1995	US 5500761 A CA 2137063 A US 5654819 A US 5589974 A	19-03-1996 28-07-1995 05-08-1997 31-12-1996